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**PATENT APPLICATION**

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Yoshitaka SASAKI et al.

Application No.: 10/067,863

Filed: February 8, 2002

Docket No.: 111926

For: WIRING PATTERN AND METHOD OF MANUFACTURING THE SAME AND  
THIN FILM MAGNETIC HEAD AND METHOD OF MANUFACTURING THE  
SAME

**PRELIMINARY AMENDMENT**

Director of the U.S. Patent and Trademark Office  
Washington, D. C. 20231

Sir:

Prior to initial examination, please amend the above-identified application as follows:

**IN THE SPECIFICATION:**

Page 24, delete lines 24-26.

Page 24, lines 4-5, delete current paragraph and insert therefor:

*A<sup>1</sup>*  
Fig. 9 is a cross sectional and plan view, respectively illustrating the known thin film  
magnetic head;

Page 24, lines 16-17, delete current paragraph and insert therefor:

*A<sup>2</sup>*  
Figs. 22A and 22B are cross sectional views representing a next manufacturing step;

Page 24, lines 18-20, delete current paragraph and insert therefor:

*A<sup>3</sup>*  
Figs. 23-31 are cross sectional views showing successive steps of an embodiment of  
the method of manufacturing a conductive pattern according to the invention; and

Page 24, lines 21-23, delete current paragraph and insert therefor: